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APPLICATION NO.	FI	LING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.
09/841,582	(04/24/2001	Kazuo Nishiyama	09792909-4979	5398
33448	7590	06/30/2006		EXAM	INER
ROBERT J			ZARNEKE, DAVID A		
LEWIS T. S'		.N YONS AND KI	ART UNIT	PAPER NUMBER	
SUITE 5450			2891		

DATE MAILED: 06/30/2006

Please find below and/or attached an Office communication concerning this application or proceeding.

		(.)				
	Application No.	Applicant(s)				
Office Action Commen	09/841,582	NISHIYAMA ET AL.				
Office Action Summary	Examiner	Art Unit				
	David A. Zarneke	2891				
The MAILING DATE of this communication a Period for Reply	ppears on the cover sheet wi	th the correspondence address				
A SHORTENED STATUTORY PERIOD FOR REF WHICHEVER IS LONGER, FROM THE MAILING - Extensions of time may be available under the provisions of 37 CFR after SIX (6) MONTHS from the mailing date of this communication. - If NO period for reply is specified above, the maximum statutory perions. - Failure to reply within the set or extended period for reply will, by state that the period for reply within the set or extended period for reply will, by state that the main the period for reply will, by state that the main the period for reply will, by state that the main the period for reply will, by state that the main that the period for reply will, by state that the main that the period for reply will, by state that the period for reply will, by state that the period for reply will be supplied to the provisions of the p	DATE OF THIS COMMUNIO 1.136(a). In no event, however, may a re- pd will apply and will expire SIX (6) MON tute, cause the application to become AB	CATION. eply be timely filed THS from the mailing date of this communication. ANDONED (35 U.S.C. § 133).				
Status						
1) Responsive to communication(s) filed on 17	April 2006.					
2a) ☐ This action is FINAL . 2b) ☑ The	This action is FINAL . 2b)⊠ This action is non-final.					
3) Since this application is in condition for allow						
closed in accordance with the practice unde	r <i>Ex parte Quayle</i> , 1935 C.D	. 11, 453 O.G. 213.				
Disposition of Claims						
 4) Claim(s) 6-9 is/are pending in the application 4a) Of the above claim(s) is/are withden 5) Claim(s) is/are allowed. 6) Claim(s) 6-9 is/are rejected. 7) Claim(s) is/are objected to. 8) Claim(s) are subject to restriction and 	rawn from consideration.					
Application Papers						
9) The specification is objected to by the Exami 10) The drawing(s) filed on is/are: a) and an applicant may not request that any objection to the Replacement drawing sheet(s) including the correction. The oath or declaration is objected to by the	ccepted or b) objected to the drawing(s) be held in abeyant ection is required if the drawing(ce. See 37 CFR 1.85(a). s) is objected to. See 37 CFR 1.121(d).				
Priority under 35 U.S.C. § 119						
12) Acknowledgment is made of a claim for foreign a) All b) Some * c) None of: 1. Certified copies of the priority docume 2. Certified copies of the priority docume 3. Copies of the certified copies of the priority docume application from the International Bure * See the attached detailed Office action for a limit of the certified copies of the priority docume application from the International Bure * See the attached detailed Office action for a limit of the certified copies of the priority docume application from the International Bure * See the attached detailed Office action for a limit of the certified copies of the priority docume application from the International Bure * See the attached detailed Office action for a limit of the priority docume application from the International Bure * See the attached detailed Office action for a limit of the priority docume application from the International Bure * See the attached detailed Office action for a limit of the priority docume application from the International Bure * See the attached detailed Office action for a limit of the priority docume application from the International Bure * See the attached detailed Office action for a limit of the priority document in the International Bure * See the attached detailed Office action for a limit of the priority document in the International Bure * See the attached detailed Office action for a limit of the priority document in the International Bure * See the attached detailed Office action for a limit of the priority document in the International Bure * See the attached detailed Office action for a limit of the priority document in the International Bure * See the attached detailed Office action for a limit of the priority document in the International Bure * See the attached detailed Office action for a limit of the International Bure * See the attached detailed Office action for a limit of the International Bure * See the attached detailed Office action for a limit of the International Bure * See the attached det	ents have been received. ents have been received in Apriority documents have been eau (PCT Rule 17.2(a)).	pplication No received in this National Stage				
Attachment(s) 1) Notice of References Cited (PTO-892) 2) Notice of Draftsperson's Patent Drawing Review (PTO-948) 3) Information Disclosure Statement(s) (PTO-1449 or PTO/SB/C Paper No(s)/Mail Date 4/28/06.	Paper No(s	ummary (PTO-413))/Mail Date Iformal Patent Application (PTO-152) 				

DETAILED ACTION

Continued Examination Under 37 CFR 1.114

A request for continued examination under 37 CFR 1.114, including the fee set forth in 37 CFR 1.17(e), was filed in this application after final rejection. Since this application is eligible for continued examination under 37 CFR 1.114, and the fee set forth in 37 CFR 1.17(e) has been timely paid, the finality of the previous Office action has been withdrawn pursuant to 37 CFR 1.114. Applicant's submission filed on 4/17/06 has been entered.

Response to Arguments

Applicant's arguments with respect to claims 6-9 have been considered but are most in view of the new ground(s) of rejection.

Claim Rejections - 35 USC § 103

The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:

(a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.

The factual inquiries set forth in *Graham* v. *John Deere Co.*, 383 U.S. 1, 148 USPQ 459 (1966), that are applied for establishing a background for determining obviousness under 35 U.S.C. 103(a) are summarized as follows:

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Art Unit: 2891

1. Determining the scope and contents of the prior art.

2. Ascertaining the differences between the prior art and the claims at issue.

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- 3. Resolving the level of ordinary skill in the pertinent art.
- Considering objective evidence present in the application indicating obviousness or nonobviousness.

This application currently names joint inventors. In considering patentability of the claims under 35 U.S.C. 103(a), the examiner presumes that the subject matter of the various claims was commonly owned at the time any inventions covered therein were made absent any evidence to the contrary. Applicant is advised of the obligation under 37 CFR 1.56 to point out the inventor and invention dates of each claim that was not commonly owned at the time a later invention was made in order for the examiner to consider the applicability of 35 U.S.C. 103(c) and potential 35 U.S.C. 102(e), (f) or (g) prior art under 35 U.S.C. 103(a).

Claims 6-9 are rejected under 35 U.S.C. 103(a) as being unpatentable over Camien et al., US Patent 5,953,588.

Camien (figure 5 & 6) teaches a pseudo wafer comprising a plurality of semiconductor chips [106] each having at least their electrodes formed solely on one surface thereof (6, 33-36), wherein interspaces between each individual one of said chips and bottom surfaces thereof are continuously covered with said protective material [104], and the chips are bonded with each other via the protective material, there being substantially none of the protective material formed on the one surface at which the electrodes are formed (figure 6 & 6, 33-36).

Art Unit: 2891

Camien, which teaches performing "desired steps" on the active surface of the dies, fails to teach the electrodes being covered with a solder material for forming a solder ball.

It would have been obvious to one of ordinary skill in the art at the time of the invention to cover the electrodes with a solder material in order to form a solder ball because solder ball formation is a conventional, well-known in the art step to perform on exposed electrodes. The use of conventional materials to perform their known functions is obvious (MPEP 2144.07).

Regarding claim 7, Camien teaches the protective material comprises either one of an organic insulating resin and an inorganic insulating material in teaching that the material can be an epoxy (6, 24+).

With respect to claim 8, Camien teaches the plurality of semiconductor chips arrayed thereon are diced at a position of said protective material between said plurality of semiconductor chips and thereafter mounted on a packaging substrate such that the protective material adjacent the side surfaces of the semiconductor chip is cut to provide substantially vertical side walls of protective material formed adjacent the sides of the semiconductor chip (6, 37+).

As to claim 9, while Camien fails to teach a solder bump is formed on said electrode, it would have been obvious to one of ordinary skill in the art at the time of the invention to cover the electrodes with a solder bump because solder bumps are a conventional, well-known in the art step to perform on exposed electrodes. The use of conventional materials to perform their known functions is obvious (MPEP 2144.07).

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Claims 6-9 are rejected under 35 U.S.C. 103(a) as being unpatentable over Paik et al., US Patent 5,879,964.

Paik (figure 5a) teaches a pseudo wafer comprising a plurality of semiconductor chips each having at least their electrodes formed solely on one surface thereof, wherein interspaces between said chips and bottom surfaces thereof are continuously covered with said protective material, and the chips are bonded with each other and further wherein the protective material adjacent the side surfaces of each semiconductor chip is cut to provide substantially vertical side walls of protective material formed adjacent the sides of the semiconductor chips.

While Paik teaches using wafer strips comprising several dice as opposed to the presently claimed individual dice, it would have been obvious to one of ordinary skill in the art at the time of the invention to use an individual die as opposed to the wafer strip of Paik because the omission of an element (in this case the extra chips) with a corresponding omission of its function is within the level of ordinary skill in the art (In re Wilson 153 USPQ 740 (CCPA 1967); In re Portz 145 USPQ 397 (CCPA 1965); In re Larson 144 USPQ 347 (CCPA 1965); In re Karlson 136 USPQ 184 (CCPA 1963); In re Listen 58 USPQ 481 (CCPA 1943); In re Porter 20 USPQ 298 (CCPA 1934)).

In re claim 7, Paik teaches the protective material comprises an epoxy (4, 21+), either is one of an organic insulating resin and an inorganic insulating material.

Regarding claim 8, Paik teaches the plurality of semiconductor chips arrayed thereon are diced at a position of said protective material between said plurality of semiconductor chips and thereafter mounted on a packaging substrate such that the

protective material adjacent the side surfaces of the semiconductor chip is cut to provide substantially vertical side walls of protective material formed adjacent the sides of the semiconductor chip.

With respect to claim 9, Paik teaches a solder bump [9] formed on said electrode.

Conclusion

Any inquiry concerning this communication from the examiner should be directed to David A. Zarneke whose telephone number is (571)-272-1937. The examiner can normally be reached on M-Th 7:30 AM-6 PM. If attempts to reach the examiner are unsuccessful, the examiner's supervisor, William Baumeister can be reached on (571)-272-1722. The fax phone number where this application is assigned is 571-273-8300. Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free). If you would like assistance from a USPTO Customer Service Representative or access to the automated information system, call 800-786-9199 (IN USA OR CANADA) or 571-272-1000.

David A. Zarneke **Primary Examiner**

June 23, 200£